Docket No.: 020732-110.694 Appl. No.: 10/807.858

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:

Docket No.: 020732-110.694

Examiner:

Art Unit:

Confirm, No.:

Applicant:

KORZENSKI, Michael B., et al.

AHMED, Shamim

Application No.:

Date Filed:

10/807,858 March 24, 2004 1765 .: 5492

Title:

COMPOSITION USEFUL FOR

Customer No.:

REMOVAL OF BOTTOM ANTI-REFLECTION COATINGS FROM

24239

PATTERNED ION-IMPLANTED PHOTORESIST WAFERS

RESPONSE TO THE MAY 2, 2007 OFFICE ACTION AND REQUEST FOR A ONE-MONTH EXTENSION UNDER 37 CFR §1.136(a) IN UNITED STATES PATENT APPLICATION NO. 10/807,858

Mail Stop Amendment Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

Sir

This responds to the May 2, 2007 Office Action in the above-identified application.

The claims of the application are set out in the following Section I (The Claims).

Remarks addressing the substance of the May 2, 2007 Office Action are set out in the Section II (Remarks) hereof.